## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

| Application Serial No  |                               |
|--|-------------------------------|
| Filing Date  | April 1, 2004                 |
| Confirmation No  | 2790                          |
| Inventor   | D. V. Nirmal Ramaswamy et al. |
| Assignee   | Micron Technology, Inc.       |
| Group Art Unit   | 1792                          |
| Examiner   | Robert M. Kunemund            |
| Attorney's Docket No   | MI22-2520                     |
| Customer No  | 021567                        |
| Title: Methods Of Depositing An Elemental Silicon-Comprising Material Over |                               |
| A Substrate  | . 5                           |

## RESPONSE TO NOVEMBER 27, 2007 FINAL OFFICE ACTION TO ACCOMPANY RCE FILING

To: Mail Stop RCE

Commissioner for Patents

P. O. Box 1450

Alexandria, VA 22313-1450

From: Jennifer J. Taylor. Ph.D. (Tel. 509-624-4276; Fax 509-838-3424)

Wells St. John P.S.

601 West First Avenue, Suite 1300

Spokane, WA 99201-3828

Responsive to the Final Office Action dated November 27, 2007, Applicant amends and remarks as follows:

## **AMENDMENTS**